

UNIVERSITI TEKNOLOGI MARA

**ENGINEERING AND TUNING
OF TA₂O₅ MORPHOLOGY
VIA ANODIZATION:
APPLICATION FOR UV SENSOR**

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Thesis submitted in fulfillment
of the requirements for the degree of
Master of Science
(Electrical Engineering)

Faculty of Electrical Engineering

November 2019

ABSTRACT

In this thesis, the Master candidate pursued the development of ultraviolet (UV) sensor or photo detector based on transition metal oxide, which is tuned and engineered in order to obtain enhanced properties. The author made informed choices regarding the usage of tantalum pentoxide (Ta_2O_5) as the model transition metal oxides. Ta_2O_5 is well investigated metal oxide, and a broad range of information regarding its fundamental properties, synthesis methods and applications is available. Its complimentary electronic nature is also required for the proposed studies in this thesis: Ta_2O_5 is a wide band gap metal oxide with band gap somewhere between 3.8 ~ 5.3 eV. This Master research focuses on the engineering and tuning morphology, crystallinity and stoichiometry of transition metal oxides in order to investigate and devise scenarios that result in the highest efficiencies for the above-mentioned model device. The author of this thesis thoroughly reviewed the physical and chemical properties, as well as methods of synthesis of Ta_2O_5 . Additionally, she also studied factors that have been previously employed for enhancing the targeted materials functionalities. This includes tuning the synthesis` parameters such as changes in volume of concentration, duration and temperature. In order to realize the aforementioned goals and create new knowledge, the author implemented his research work in two distinct investigations: the first investigation involved with optimizing the nanostructured of Ta_2O_5 by using anodization method. At the time when this Master research commenced, the majority of work in the field of metal oxide UV sensors has been devoted to nanostructured TiO_2 and ZnO metal oxide, whilst the number of reports on the UV sensing properties of nanostructured Ta_2O_5 was significantly lower. As a result, the Master candidate studied the UV sensing device based on nanostructured Ta_2O_5 , synthesized *via* anodization method with different fabrication parameters. As the aim of this thesis, the author demonstrated control over crystallinity, pore sizes and surface roughness of the films by altering the volume concentration and duration of anodization. The author provided organized and step by step discussion on how NH_4F , H_2O and H_2SO_4 influence the growth of nanotubular by performing the experiments with different concentration of NH_4F , H_2O and H_2SO_4 . The author found out that optimized condition to successfully synthesize nanotubular Ta_2O_5 is 50 mL EG + 1.35 wt% NH_4F + 4 vol% H_2O + 0.5 vol% H_2SO_4 , with annealing temperature of 500 °C for 2 h. Moreover, UV sensor fabricated from nanotubular Ta_2O_5 anodized for 1.5 hour was yielding the highest sensor`s efficiency with fastest responsivity, highest repeatability value and lowest resistance value. In summary, the author strongly believes that this thesis provides the readers with an in-depth knowledge of capabilities that tuning and engineering Ta_2O_5 provide in enhancing the performance of such materials for UV sensor. This study is expected to open the way for the development of large-scale nanotubular Ta_2O_5 UV sensor with optimum UV responsivity and stability.

ACKNOWLEDGEMENT

First and foremost, I would like to express my deepest gratitude to my supervisor, Associate Professor Ir. Ts. Dr. Ahmad Sabirin Zoofakar for his advice, encouragement and guidance throughout the research. His enthusiasm and passion for work, not only educated me in the technical field but also in real life. My thesis would not have been possible without his excellent supervision. I thank him from the bottom of my heart on his effort to educate me, despite of my weakness and lack of knowledge. I would also like to express my gratitude to my co-supervisor; Dr. Mohamad Hafiz Bin Mamat and Dr. Muhammad Farid Bin Abdul Khalid for their support and facilities for this research.

I am gratefully acknowledged NANO-Electronic Centre (NET)'s and NANO SciTech Centre staffs, especially Mr. Azwan, Mr. Suhaimi, Mr. Azrul and Mrs. Nurul. I wish to extend my appreciation to my lab mates; Ms. Katrul Nadia and Ms. Samihah, for their help, motivation, kindness and support during my studies. My special thanks to Faculty of Applied Science for their X-Ray Diffraction facilities. I also would like to thank Ministry of Higher Education Malaysia and Universiti Teknologi MARA for the GIP grant (Project Code: 600-IRMI/MyRA 5/3/GIP (070/2017)) for the financial support.

This work and thesis may not be possible without the help and understanding from my parents Abu Talip Bin Jaafar and [REDACTED] and my supportive siblings, especially my late sister Norliza Binti Abu Talip. Words cannot express my deep gratitude for the patience and support all through these years. I am blessed with a wonderful family I have, and I thank God for that.

TABLE OF CONTENTS

| | Page |
|---|-------------|
| CONFIRMATION BY PANEL OF EXAMINERS | ii |
| AUTHOR'S DECLARATION | iii |
| ABSTRACT | iv |
| ACKNOWLEDGEMENT | v |
| TABLE OF CONTENTS | vi |
| LIST OF TABLES | ix |
| LIST OF FIGURES | x |
| LIST OF SYMBOLS | xiv |
| LIST OF ABBREVIATIONS | xv |
| | |
| CHAPTER ONE : INTRODUCTION | 1 |
| 1.1 Research Background | 1 |
| 1.2 Problem Statement | 3 |
| 1.3 Objectives | 4 |
| 1.4 Significance of Study | 4 |
| 1.5 Thesis Outline | 5 |
| | |
| CHAPTER TWO : LITERATURE REVIEW | 6 |
| 2.1 Introduction | 6 |
| 2.2 Fundamental properties of Ta ₂ O ₅ | 6 |
| 2.2.1 Crystal Structure | 6 |
| 2.2.2 Electronic Band Structure | 10 |
| 2.2.3 Optical and Electronic Properties | 12 |
| 2.3 Nanostructured Ta ₂ O ₅ Synthesis Methods | 13 |
| 2.3.1 Gas (Vapour) Phase Fabrication | 13 |
| 2.3.2 Liquid Phase Fabrication | 20 |
| 2.4 Applications Ta ₂ O ₅ | 28 |
| 2.4.1 Resistance Switching Memories (RRAMs) | 28 |
| 2.4.2 Photocatalysts | 29 |

| | | |
|---|--|-----------|
| 2.4.3 | Sensors | 31 |
| 2.5 | Chapter Summary | 33 |
| CHAPTER THREE : RESEARCH METHODOLOGY | | 34 |
| 3.1 | Introduction | 34 |
| 3.2 | The Anodization of Nanotubular Ta ₂ O ₅ | 34 |
| 3.2.1 | Preparation of Ta Foil | 35 |
| 3.2.2 | Preparation of Electrolyte Solution | 38 |
| 3.2.3 | Preparation of Anodization Setup | 41 |
| 3.2.4 | Annealing Ta ₂ O ₅ film | 43 |
| 3.2.5 | Nanotubular Ta ₂ O ₅ Characterization | 44 |
| 3.3 | The Fabrication of Nanotubular Ta ₂ O ₅ -based UV Sensor | 48 |
| 3.3.1 | Deposition of Pt on Ta ₂ O ₅ film | 48 |
| 3.3.2 | Preparing UV Sensing Measurement Setup | 50 |
| 3.3.3 | Characterizing UV Sensor | 52 |
| 3.4 | Chapter Summary | 53 |
| CHAPTER FOUR : RESULTS AND DISCUSSION ON CHARACTERIZATION OF NANOTUBULAR TA₂O₅ FABRICATED VIA ANODIZATION & TA₂O₅ UV SENSOR. | | 54 |
| 4.1 | Introduction | 54 |
| 4.2 | Optimization of NH ₄ F Concentration in Electrolyte | 56 |
| 4.3 | Optimization of H ₂ O Concentration in Electrolyte | 59 |
| 4.4 | Optimization of H ₂ SO ₄ Concentration in Electrolyte | 63 |
| 4.5 | Annealing Optimization of Ta ₂ O ₅ | 66 |
| 4.6 | Effect of Anodization Duration on Nanotubular Ta ₂ O ₅ Films | 68 |
| 4.7 | Growth Mechanism of Nanotubular Ta ₂ O ₅ Structure | 73 |
| 4.8 | UV Sensing Mechanism | 77 |
| 4.9 | Responsivity | 82 |
| 4.10 | Repeatability | 85 |
| 4.11 | Resistance | 85 |
| 4.12 | Chapter Summary | 87 |